#26/EDocket No. 0756-1986

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of

Yasuhiko TAKEMURA

Serial No. 09/342,235

Filed: June 29, 1999

SEMICONDUCTOR DEVICE For:

HAVING AT LEAST FIRST AND

SECOND THIN FILM

**TRANSISTORS** 

Group Art Unit: 2814

) Examiner: Ahmed N. Sefer

## **CERTIFICATE OF MAILING**

I hereby certify that this correspondence is being deposited with The United States Postal Service with sufficient postage as First Class Mail in an envelope addressed to: Commissioner for Patents, Washington, D.C. 20231, an February 24, 2003.

Adele M. Stamper

<u>AMENDMENT</u>

Honorable Commissioner for Patents

Washington, D.C. 20231

Sir:

In response to the Office Action dated October 23, 2002, please amend ove-identified application as follows: the above-identified application as follows:

## IN THE CLAIMS:

13. (Amended) A semiconductor device comprising:

a substrate having an insulating surface;

at least first and second semiconductor islands formed directly on said insulating surface wherein each of the semiconductor islands has a channel region and a pair of impurity regions;

a first and a second gate insulating film formed over said semiconductor island, respectively;